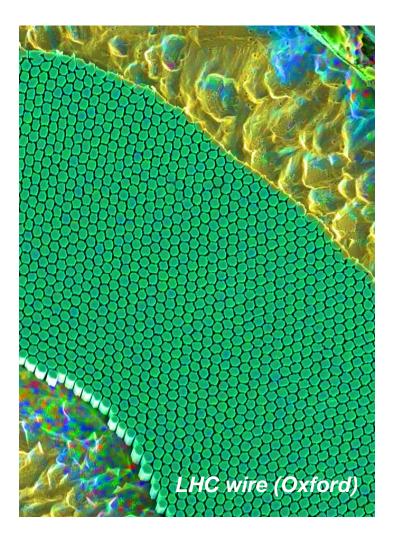
### Advances in low loss NbTi Strand and Cable Martin Wilson

#### Plan

- Recapitulate general loss mechanisms
- Hysteresis loss fine filaments proximity coupling etc
- Coupling loss within wires transverse resistivity, barriers, stability
- Coupling loss between cables interface resistance, stability, cores



### AC loss general

- work done to change the field energy  $\delta E = H \delta B$
- around a closed loop, energy dissipated in a magnetic material  $E = \oint \mu_o H dM = \oint \mu_o M dH$
- away from end points, loss power  $P = M\dot{B}$
- superconductor magnetization comes from
  - supercurrents  $\Rightarrow$  hysteresis
  - combined supercurrents and resistive currents  $\Rightarrow$  coupling
  - classical eddy currents
- with a transport current flowing, the power supply also does work, increasing the loss by a factor

Hysteresis

• for round filaments

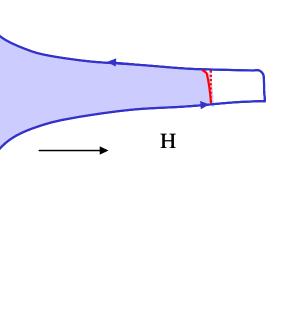
Martin Wilson slide #2

 $M = \frac{2}{3\pi} J_c d_f$ 

$$P = \dot{B} \frac{2}{3\pi} J_c d_f$$

 $l + \left(\frac{I_t}{I_c}\right)^2$ 

 $\Rightarrow$  fine filaments



Μ

# Making fine filaments: resistive transition

• resistive transition

$$(J) = \rho_o \left\{ \frac{J}{J_o} \right\}^n$$

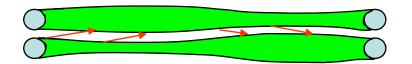
• depends on processing - 'sausaging'

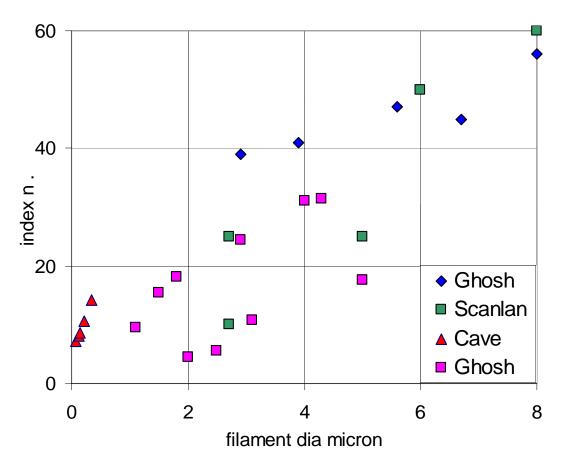
ρ

- *n* always gets worse with finer filaments, so useful *J* gets less
- but intrinsic  $J_c$  does not get worse

### Intermetallics

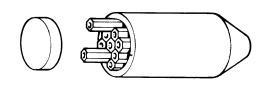
- CuTi intermetallic particles formed during extrusion pre-heat
- they don't draw down with the filaments ⇒ breakage
- must surround filament with diffusion barrier usually Nb



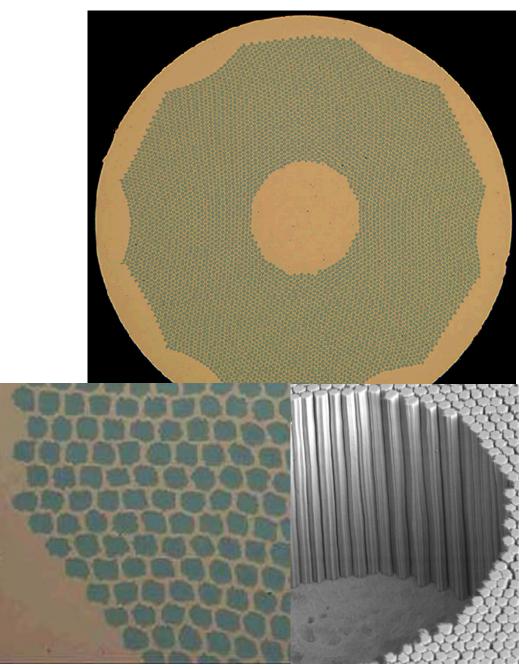


Making fine filaments: Single stacking

- single stacking makes the best wire
- when packing the extrusion cannister, rods buckle below ~ 1.5mm diameter
   ⇒ filament crossover ⇒ breakage
- for a 250mm diameter extrusion cannister, this limits the number of filaments to ~15,000



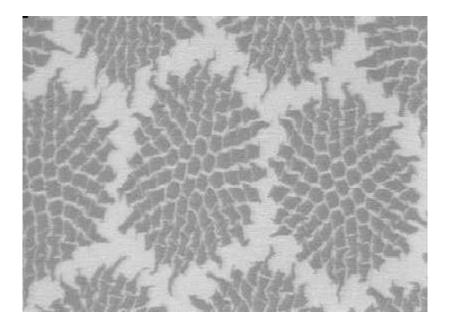
 for a 0.85mm diameter wire, 15,000 filaments
 ⇒ diameter ~ 4.5µm

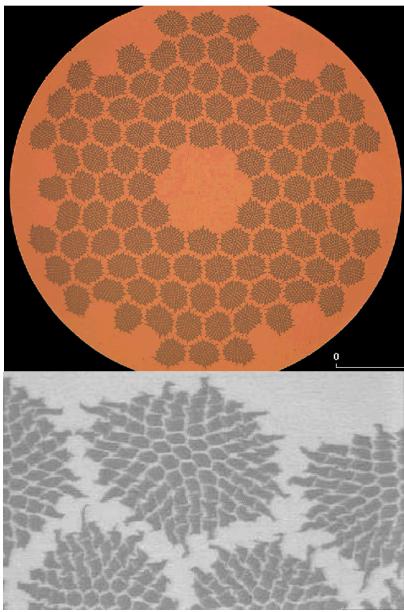


wire 3N7 by European Advanced Superconductors

Making fine filaments: Double stacking

- double stacking is easier and allows a large number of filaments
- but the filaments are more distorted





wire 2A212 by European Advanced Superconductors

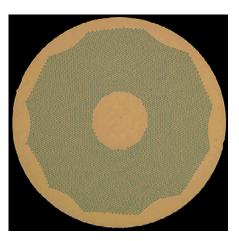
*Fine filaments: distortion* 

- measure magnetization extrapolated to zero B` and  $J_c$  via transport current (measure at high field to minimize self field)
- calculate ratio

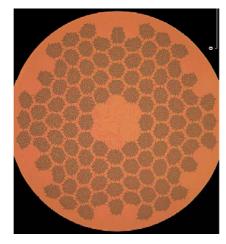
 $r = \frac{J_{cmag}}{J_{ct}}$ 



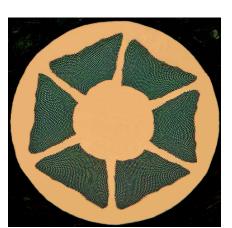
Oxford RHIC: r = 0.92



EAS 3N7: r = 0.94

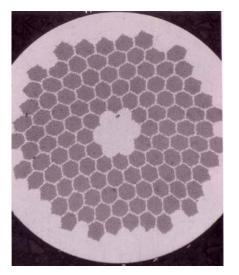


EAS 2A212: r = 1.40



EAS K2001T4: r = 1.15





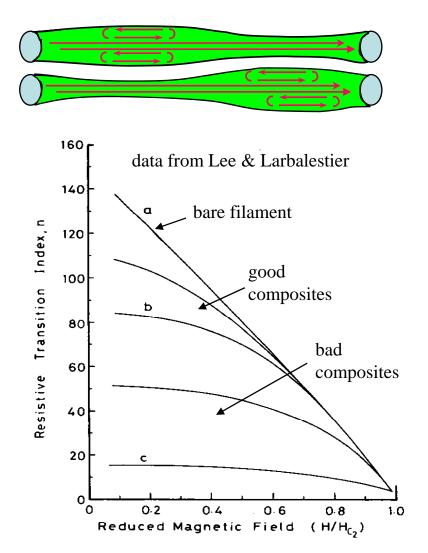
EAS G2001T6: r = 1.10

IGC SSC B944-2 (CuMn around filaments) r = 1.23

wire 2A212 by European Advanced Superconductors

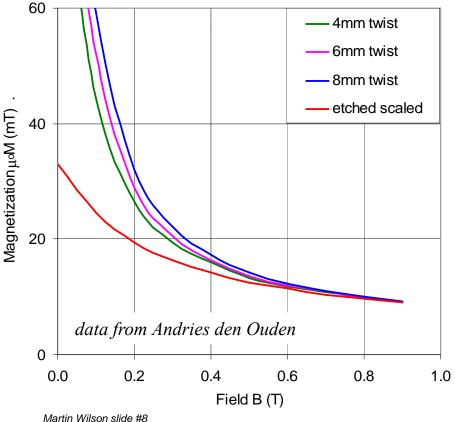
## Fine filament distortion: why is r < 1?

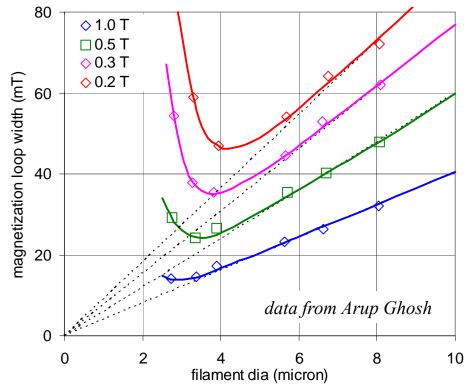
- transport current determined by narrowest paths
- magnetization current fills up the rest
- so  $r = \frac{J_{cmag}}{J_{ct}}$  should be > 1
- but  $J_{ct}$  is measured with a certain electric field usually 10<sup>-14</sup>  $\Omega$ m
- $J_{cmag}$  is measured with zero electric field
- even bare filaments have an 'n' value
- estimate the decay of magnetization currents
- for n = 100 and a 6 µm filament, after 100 sec,  $J_{cmag}$  will have decayed to 88% of its  $10^{-14} \Omega m$  value



# Fine filaments: proximity coupling

- magnetization reduces with filament diameter down to a point - then it increases
- effect is strongest at low field

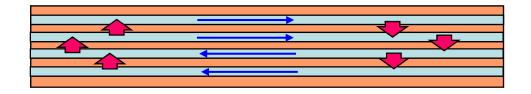




- expected linear decrease is restored when filaments are etched
- enhancement of magnetization is • ~ (twist pitch)  $^{-1}$

## Fine filaments: proximity coupling

• experimental data on etching suggests that the effect is caused by supercurrents crossing the matrix

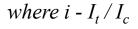


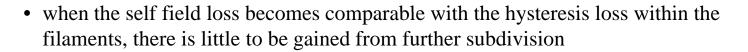
- linear dependence on twist pitch suggests these currents have a  $J_c$
- Ghosh finds that transverse current density is given by  $J_{\perp} = J_o e^{-ks}$  where *s* is the separation between the filaments and *k* depends on field and temperature
- for minimum sausaging and optimum wire yield, must have  $s/d \sim 0.15$ , where s is space between filaments and d is filament diameter so  $3\mu$ m filaments  $\Rightarrow 0.45\mu$ m separation
- Collings finds that transverse currents are suppressed by ferromagnetic additions to the matrix metal 0.5% Mn in copper works well
- adding Si to copper also suppresses proximity currents and also reduces CuTi formation during extrusion
- Sumption found that a wire made by (low temperature) hydrostatic extrusion without Nb diffusion barriers had no proximity coupling down to 2µm filament diameter - perhaps the Nb barriers help to launch Cooper pairs across the copper

## Fine filaments: how many?

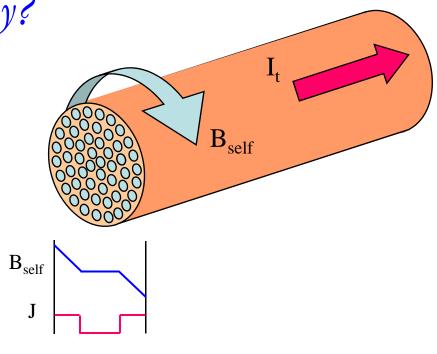
- self field, due to transport current penetrates from the outside of the wire
- $J_c$  in outer filaments nothing inside
- twisting makes no difference
- penetration produces self field losss (per ramp)

$$Q_{s} = \frac{B_{s}^{2}}{2\mu_{o}} \left\{ \frac{4}{i} - 1 + 4 \frac{(2-i)}{i^{2}} ln\left(\frac{2-i}{2}\right) \right\}$$





• for example, a 0.8mm diameter wire with 10<sup>5</sup> filaments of 2µm diameter will have  $Q_s / Q_h \sim 50\%$  when ramped from 1T to 6T with i = 0.7



### Eddy current coupling between filaments in wires

• currents flow along filament and across matrix parallel to field

 $M = \frac{2}{\mu_o} \dot{B} \tau$ 

 $\tau = \frac{\mu_o}{2\rho_{ot}} \left(\frac{p}{2\pi}\right)^2$ 

- induced magnetization
- current decay time

loss power 
$$P = \frac{\dot{B}_i^2}{\mu_o} 2\tau = \frac{\dot{B}_i^2}{\rho_{et}} \left(\frac{p}{2\pi}\right)^2$$

where  $p = twist pitch and \rho_{et}$  is the effective transverse resistivity across the matrix

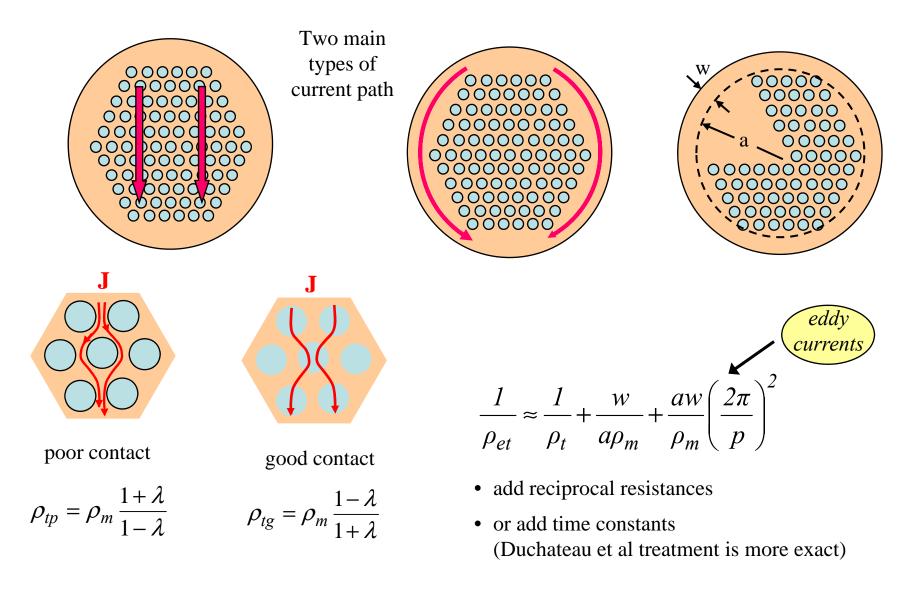
• general formulation in terms of multiple time constants\*

$$P = \frac{2\dot{B}_{i}^{2}}{\mu_{o}} \sum_{n} \tau_{1} + \tau_{2} + \tau_{3} \dots$$

\*Duchateau, Turck and Ciazynski: Handbook on Applied Superconductivity B4.3

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### Effective transverse resistivity



### Matrix resistance

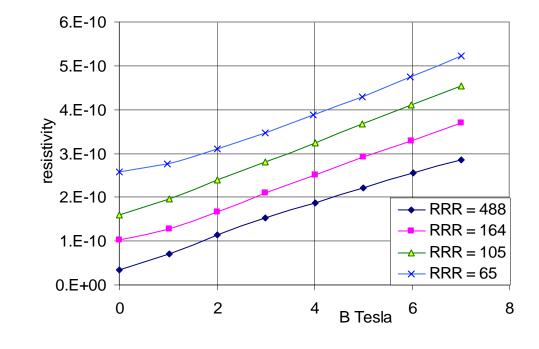
#### 1) Magnetoresistance

- lots of good data from Fickett
- all for perpendicular B

 $\rho(B) = (l+r) \rho_{B=0}$ 

• but it's all we have - fitted by

 $\beta = \log\left\{\frac{15.5 \times 10^{-9} B}{\rho_{B=0}}\right\}$ 



 $log(r) = -2.66 + 0.317 \ \beta + 0.623 \ \beta^2 - 0.184 \ \beta^3 + 0.0183 \ \beta^4$ 

#### 2) Size effect

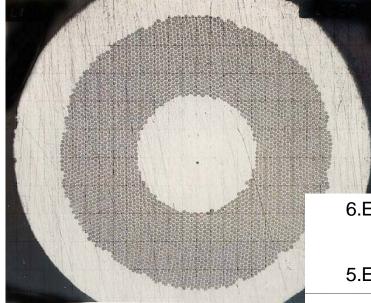
• separation of filaments is comparable with electron mean free path  $\Rightarrow$  increase in resistivity to  $\rho_s$   $\rho_s$ 

$$\rho_s = \rho_o(l + l/s)$$

where *l* is the electro mean free path; for copper  $\rho_o l = 6.45 \times 10^{-16} \Omega m^2$ 

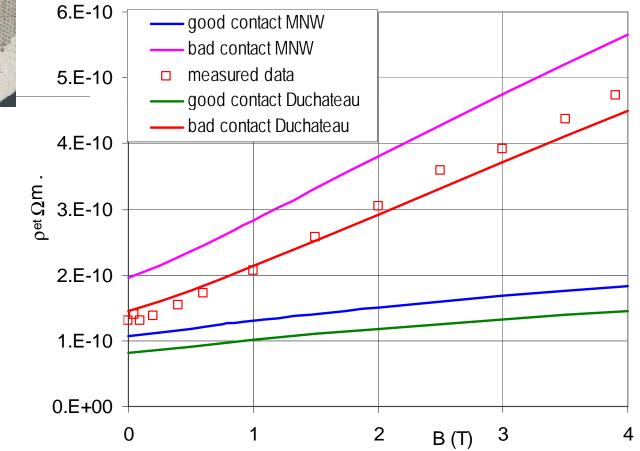
• example: for RRR= 150 and an inter-filament spacing of  $1\mu m$ , the resistivity of copper between filaments is increased by a factor 6.7

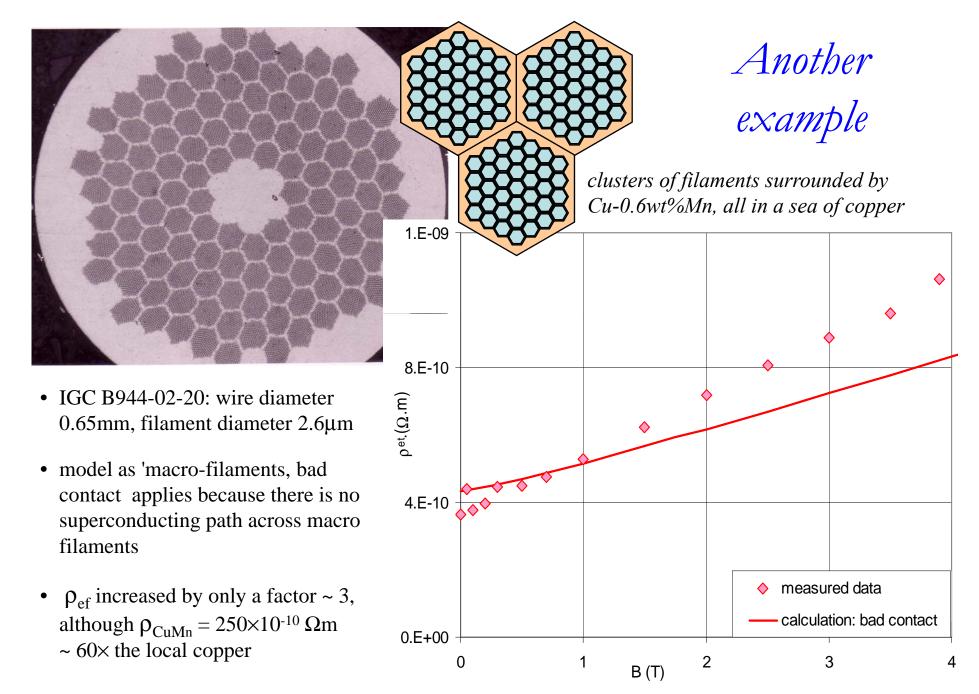
Martin Wilson slide #13



- RHIC wire with 6µm filaments and 13mm twist pitch
- theory of Duchateau fits better because it includes the central island
- good or poor contact?
  - measure it!

## Calculated and measured $\rho_{et}$

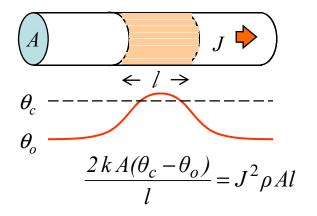




Martin Wilson slide #15

## Constraints on increasing $\rho_{et}$

#### Crude model for MQE



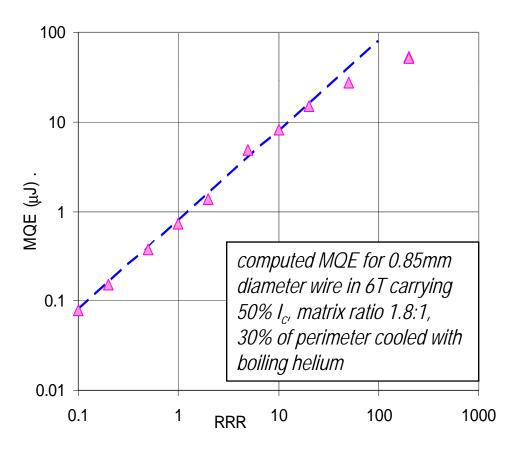
(all parameters averaged over the cross section)

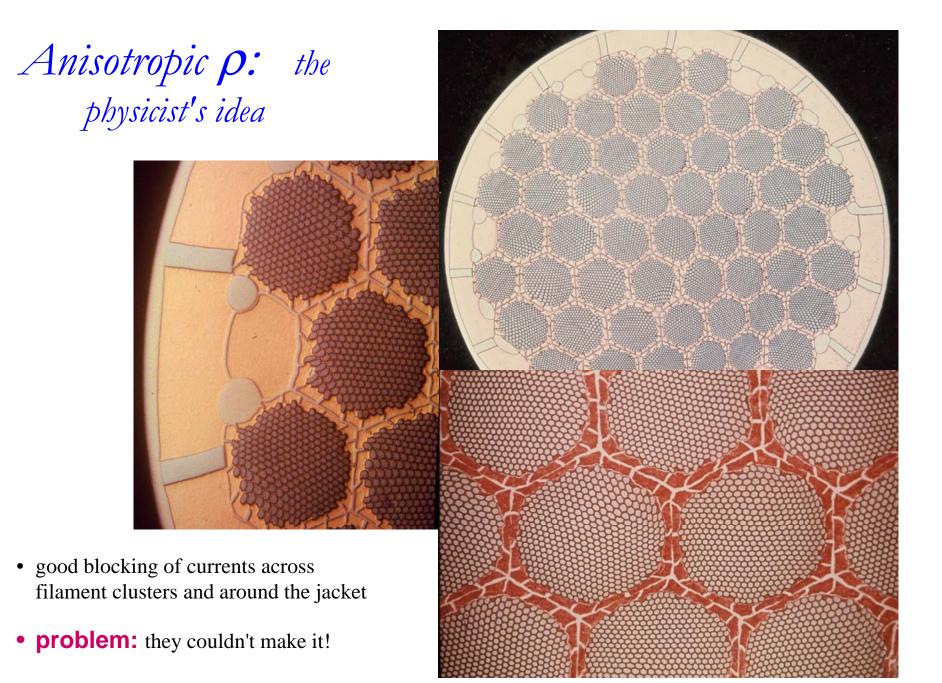
$$l = \left\{ \frac{2k(\theta_c - \theta_o)}{J^2 \rho} \right\}^{\frac{1}{2}} \cong \frac{\left[ L_o \left( \theta_c^2 - \theta_o^2 \right) \right]^{\frac{1}{2}}}{J_c \rho}$$

(using Wiedemann Franz Law L<sub>o</sub> = Lorentz number)

**Conclude:** need matrix with a resistivity which is low in longitudinal and high in transverse directions - anisotropic material

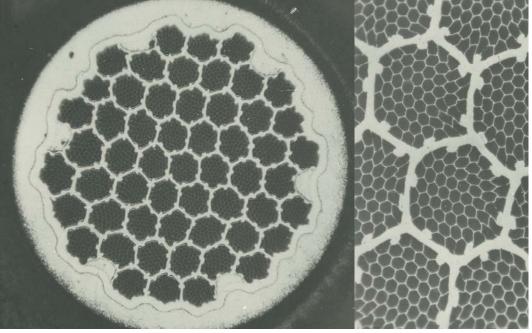
- use resistive alloy in the matrix
- but conflict with stability (early experiments on training)
- take minimum quench energy MQE as a criterion of stability

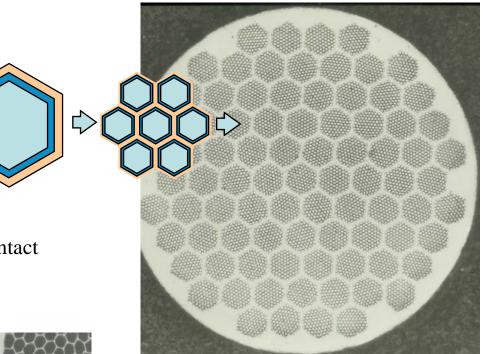




Anisotropic p: the wire maker's idea

- barrier round each filament, immerse in a sea of copper
- good mechanical properties for drawing
- **problem:** only change  $\rho_t$  from good to bad contact
- problem: conduction round the outer jacket



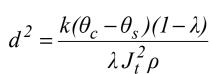


#### idea 2

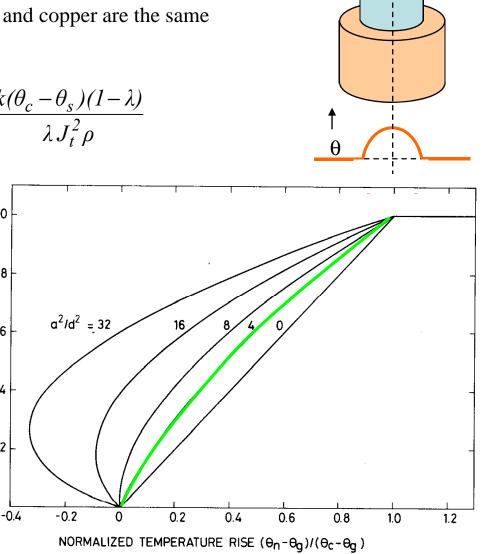
- resistive material throughout the core
- thick barrier between core and jacket
- copper jacket
- low losses
- **problem:** stability the copper is too far from the filaments

### Stability: do filaments see the copper?

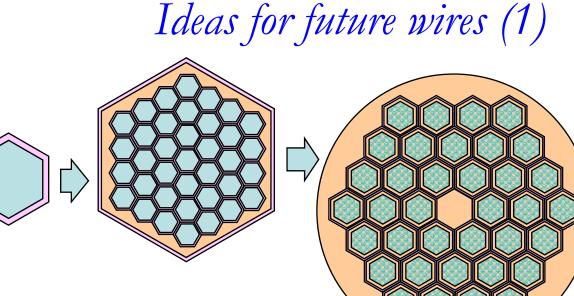
- MQE analysis assumes that the NbTi are intimately mixed how intimate?
- over long lengths the electric field in NbTi and copper are the same
- what about the temperature? - uniform over Cu but not NbTi
- define a characteristic distance where k = thermal conductivity of NbTi,  $\theta_s =$ current sharing temperature,  $J_t$  = transport current density in NbTi,  $\lambda$  = local filling factor,  $\rho$  = copper resistivity, a = filament radius
- solve for power generation as a function of copper temperature  $\theta_n$
- for acceptable behaviour choose  $a^2/d^2 < 4$ , ie  $d_{fil} < 4d$
- for NbTi in Cu at 6T d ~ 10μm
- so require  $d_{fil} < 40 \mu m$
- a mixture of NbTi and CnMn typically has  $k \sim 10 \times k_{NbTi}$
- so macro filament diameter can be ~ 120µm

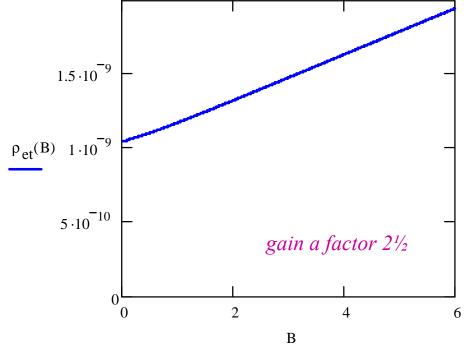


1.0



- barriers more efficient in blocking crossing current
- still respect the dynamic stability condition
- CuMn next to filament to suppress proximity coupling

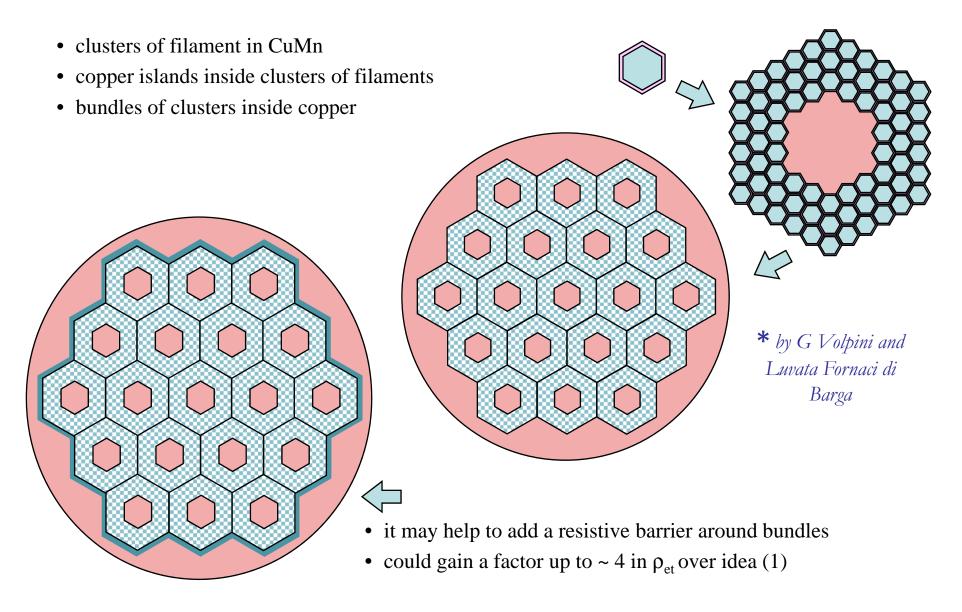


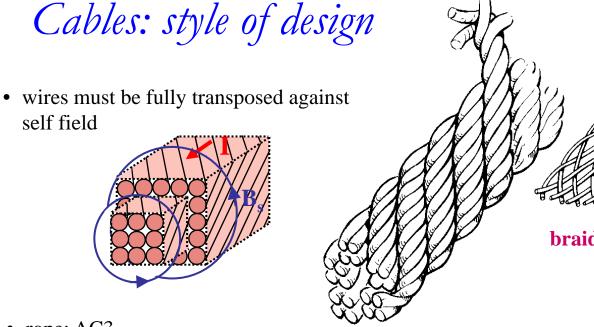


resistivity across the core	$ ho_{ec}(0)$	1.1×10 <sup>-8</sup> Ωm
resistivity across the filamentary region	ρ <sub>ef</sub> (0)	2.6×10 <sup>-9</sup> Ωm
around the outer barrier	$ ho_{eb}$ (0)	7.4×10 <sup>-8</sup> Ωm
around the outer Cu jacket	$ ho_{eo}(0)$	2.5×10 <sup>-9</sup> Ωm
overall transverse resistivity for the wire	ρ <sub>et</sub> (0)	1.11×10 <sup>-9</sup> Ωm

Martin Wilson slide #20

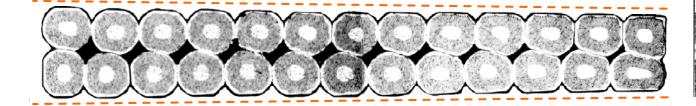
## Ideas for future wires (2) - a better idea\*

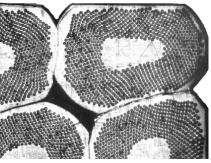


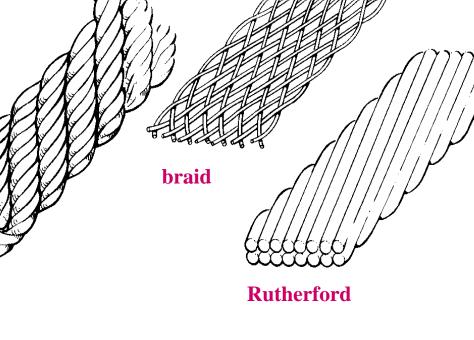


rope

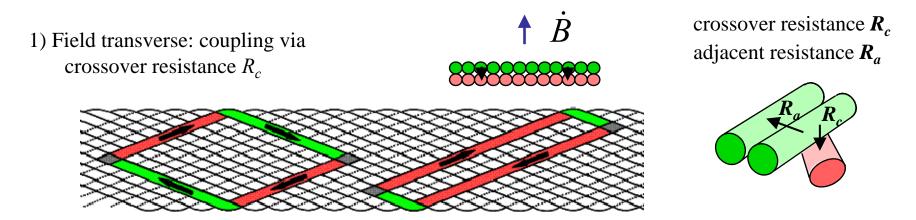
- rope: AC3
- braid: MOBY and early RHIC
- Rutherford: AC5 and Tevatron
- Rutherford probably won because it can be compacted to high density and tolerance



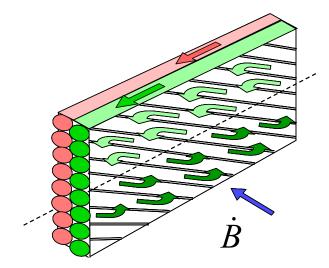




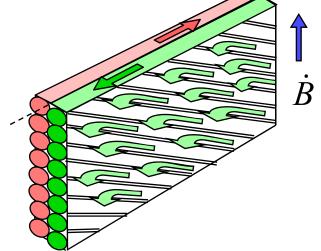




2) Field transverse: coupling via adjacent resistance  $R_a$ 



3) Field parallel: coupling via adjacent resistance  $R_a$ 



Coupling magnetization in cables• Field transverse  
coupling via crossover
$$M_{tc} = \frac{1}{6\theta} \frac{\dot{B}_t}{r_c} p^2 \frac{c^2}{b}$$
$$M_{tc} = \frac{1}{120} \frac{\dot{B}_t}{R_c} p \frac{c}{b} N(N-1)$$
$$M_{tc} = \frac{1}{2c} \frac{\dot{B}_t}{b} p \frac{c}{b} N(N-1)$$
where  $M$  = magnetization per unit volume of cable,  $p$  twist pitch,  $N$  = number of strands  
 $r_c$  and  $r_a$  are resistance  $*$  unit area of contact,  $R_c$  and  $R_a$  are resistance per contact• Field transverse  
coupling via adjacent resistance  $R_a$   
where  $\theta$  = slope angle of wires  $Cos \theta \sim 1$ 
$$M_{ta} = \frac{1}{12} \frac{\dot{B}_t}{r_a} \frac{p^2}{c cos \theta}$$
$$M_{ta} = \frac{1}{6} \frac{\dot{B}_t}{R_a} p \frac{c}{b}$$
  
(usually  
negligible)• Field transverse  
resistance  $R_a$   
where  $R_a$ 
$$M_{pa} = \frac{1}{16} \frac{\dot{B}_p}{r_a} \frac{p^2}{c cos \theta}$$
$$M_{pa} = \frac{1}{8} \frac{\dot{B}_p}{R_a} p \frac{b}{c}$$
  
(usually  
negligible)• Field transverse  
ratio crossover/adjacent  
ratio crossover/adjacent
$$M_{tc} = \frac{R_a}{R_c} \frac{N(N-1)}{20} \approx 45 \frac{R_a}{R_c}$$
(usually  
negligible)• So without increasing loss too much can make  $R_a$   
much less than  $R_c$  - anisotropy

Martin Wilson slide #24

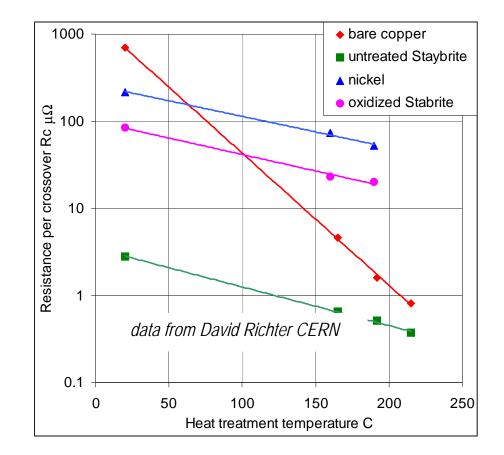
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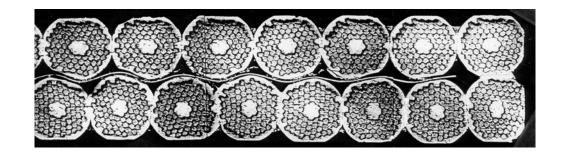
R<sub>a</sub> and R<sub>c</sub>

- we can increase (and reduce losses)  $R_a$  and  $R_c$  by surface coatings and creative chemistry
- but do we want them to be too large?
- worries about stability and current sharing
- memories of MOBY and Rutherford quadrupole, type A/B behaviour in SSC booster dipoles
- suggest we should make  $R_a$  and  $R_c$  as large as necessary to limit the loss but no larger
- because the loss is anisotropic, it pays to make  $R_a$  and  $R_c$  anisotropic



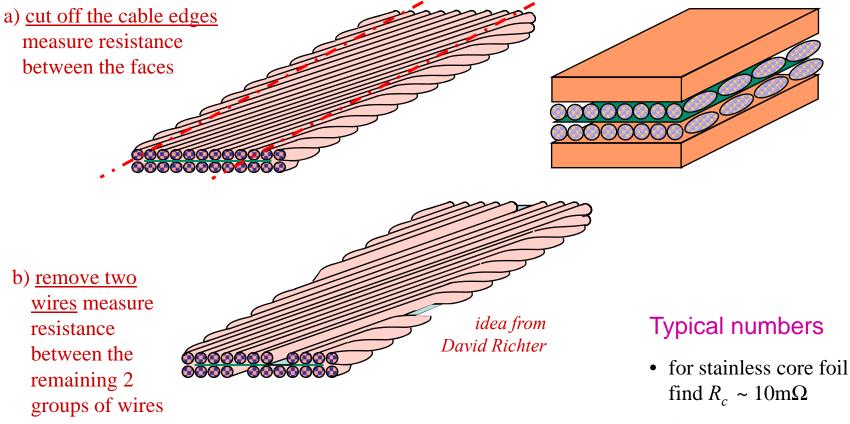
$$\frac{M_{tc}}{M_{ta}} = \frac{R_a}{R_c} \frac{N(N-1)}{20} \approx 45 \frac{R_a}{R_c}$$

- cored cable, make  $R_c \sim 40 \times R_a$
- lower losses with good stability



## Measuring $r_c$ when it's >> $r_a$

Usually, only a tiny fraction of current goes through the core, making it difficult to measure  $r_c$  in an intact cable. Two methods of forcing current through the core:



• for FAIR target  $R_a \sim 200 \mu \Omega$ 

## Measuring cable stability

• use carbon paste heaters to inject short energy pulses to individual strands • measure the MQE CURRENT RETURN HEATER COPPER STRIP 10000 INSULATION 1000 QE (IJ) • it looks like low  $R_a$  is best 100 but how much does it • •  $R_a < 1\mu\Omega$  (soldered) really tell us about  $\blacksquare R_a = 60 - 70\mu\Omega$ magnet stability?  $\blacktriangle R_a = 600 - 700\mu\Omega$ •  $R_a = 8 - 9 \text{ m}\Omega$ 10 0.40 0.50 0.60 0.70 0.80 0.90 1.00 I/Ic (-) measurements courtesy of Gerard Willering

### Low loss NbTi Strand & Cable: concluding remarks

#### ♦ Hysteresis Loss

- usually dominant  $\Rightarrow$  many very fine filaments (but not too many or self field loss)
- filament distortion: longitudinal  $\Rightarrow$  low *n* transverse  $\Rightarrow$  enhanced magnetization
- intermetallics: diffusion barriers or low temperature extrusion
- stacking: single stack  $\Rightarrow$  best properties double stack  $\Rightarrow$  more filaments
- proximity coupling: ferromagnetic additions to copper CuMn or no diffusion barrier

#### $\diamond$ Coupling between filaments

- anisotropic matrix resistance high transverse  $\Rightarrow$  low loss, low longitudinal  $\Rightarrow$  stability
- MQE gives estimate of stability critical distance for intimate mixing of NbTi and Cu
- new ideas needed for higher transverse resistance without loosing stability

#### $\diamond$ Cables

• the high interface resistance needed to control losses high ramp rate may prejudice stability - surface coatings  $\Rightarrow R_a > R_c$ , - core  $\Rightarrow R_a << R_c \Rightarrow$  low loss without losing stability

#### ♦ NbTi

- now into middle age, NbTi still offers substantial advantages for pulsed use:
  - the finest filaments, low filament distortion,
  - precise fine structures of resistive alloy and copper in the matrix with no mixing
  - ductility